

[54] PHOTOMETRIC ANALYSIS APPARATUS

[75] Inventor: Enzo Sergio Mannucci, Siena, Italy
[73] Assignee: Istituto Sieroterapico e Vaccinogeno
Toscano "Sclavo" S.p.A., Siena, Italy

[**] Term: 14 Years

[21] Appl. No.: 683,229

[22] Filed: May 4, 1976

[30] Foreign Application Priority Data
Nov. 7, 1975 Italy 11830/75

[51] Int. Cl. D24-02; D10-04
[52] U.S. Cl. D10/46
[58] Field of Search D32/2 C; 356/184, 183;
D10/46; D24/8, 17

References Cited			
U.S. PATENT DOCUMENTS			
3,026,182	3/1962	Jankowski	D32/2 C
D. 209,823	1/1968	Waligorski	D32/2 C
D. 211,634	7/1968	Derkas et al.	D32/2 C
D. 217,987	7/1970	Casterlin	D32/2 C
D. 217,988	7/1970	Casterlin	D32/2 C
D. 223,349	4/1972	Minas	D32/2 C

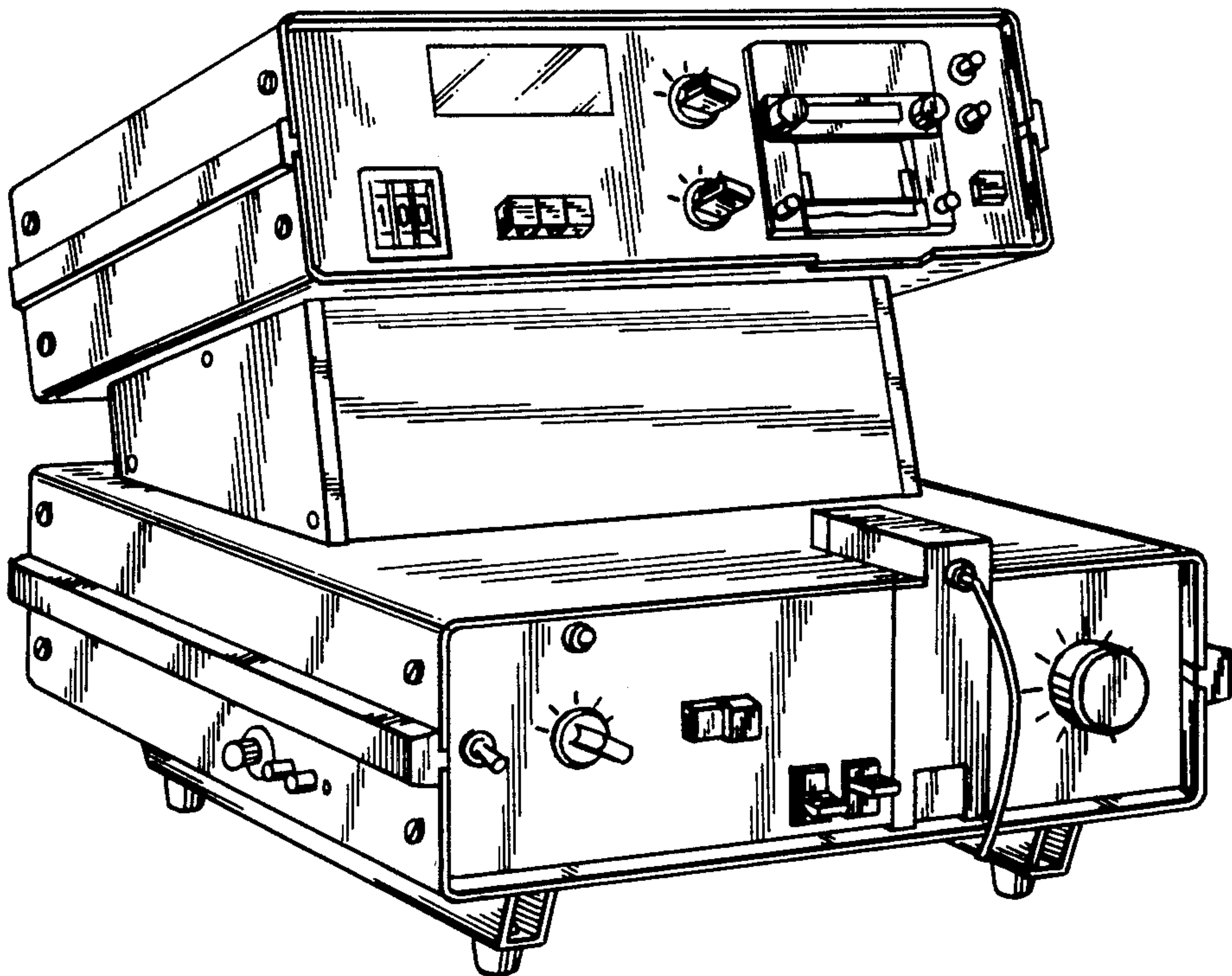
Primary Examiner—Bernard Ansher
Attorney, Agent, or Firm—Eric H. Waters

[57] CLAIM

The ornamental design for a photometric analysis apparatus, as shown.

DESCRIPTION

FIG. 1 is an front perspective view of the photometric analysis apparatus embodying my new design;
FIG. 2 is a front elevation thereof;
FIG. 3 is a top plan view of the apparatus;
FIG. 4 is one of the side views, the other being substantially identical; and
FIG. 5 being a rear view of the apparatus.



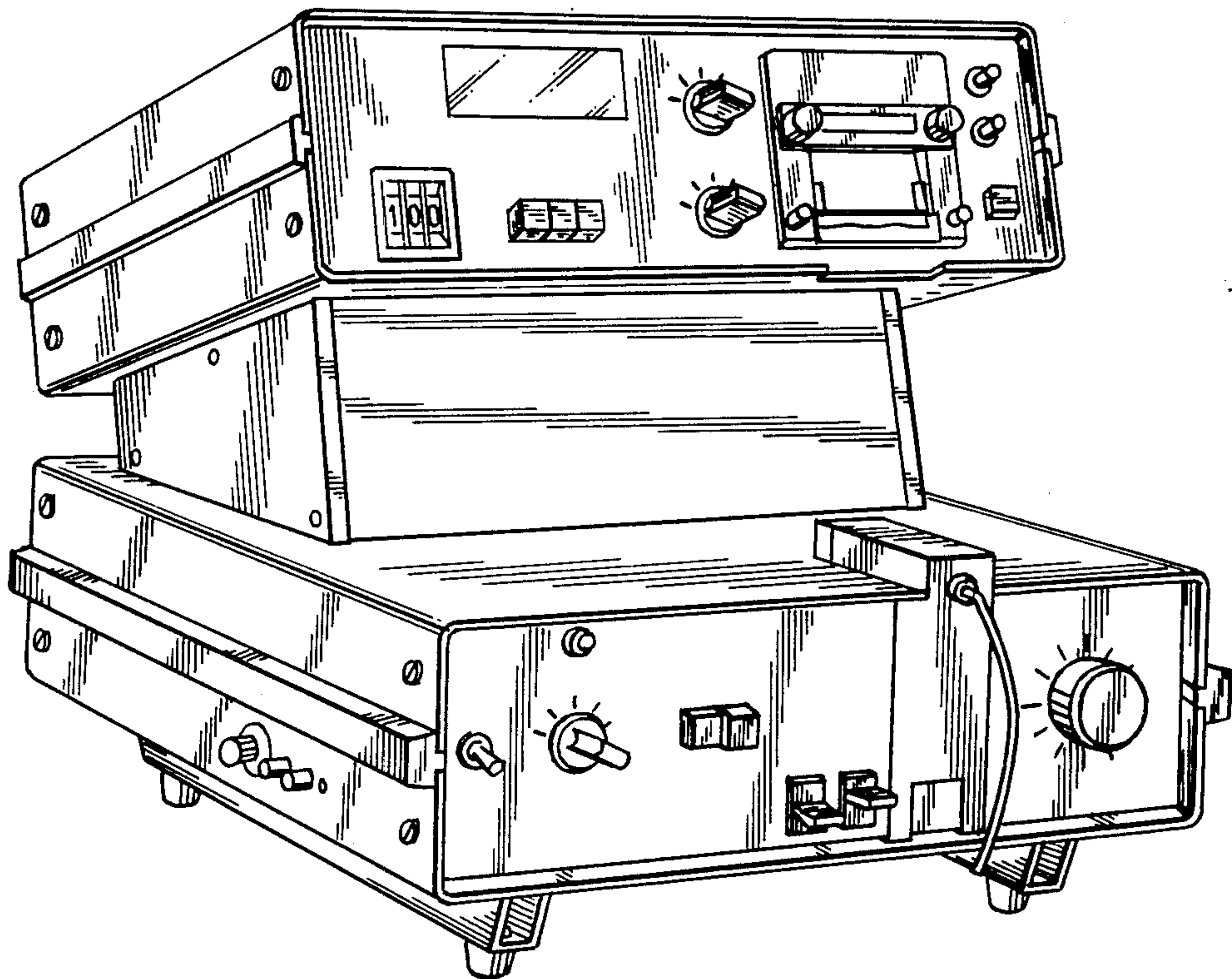


FIG. 1

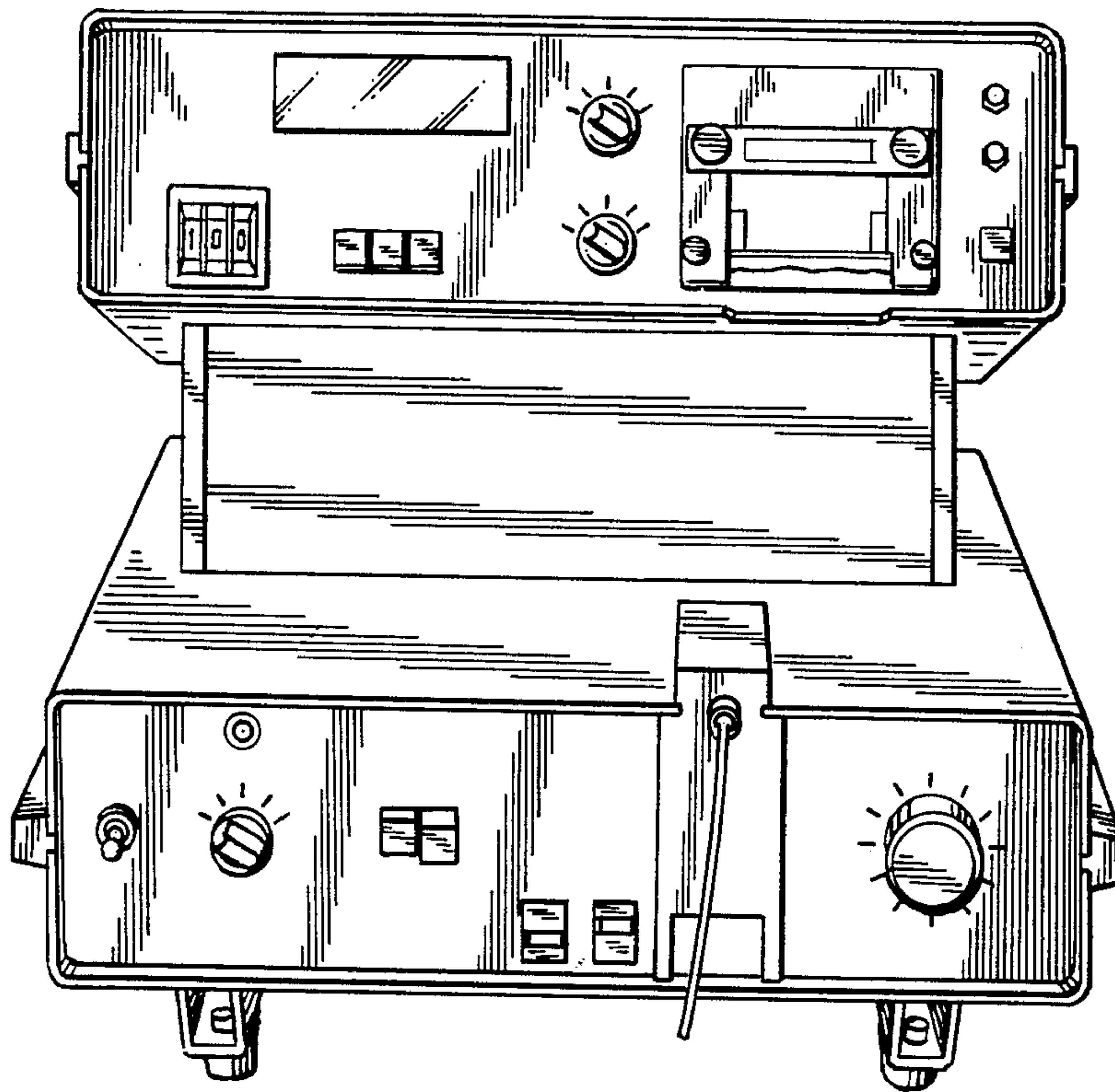


FIG.2

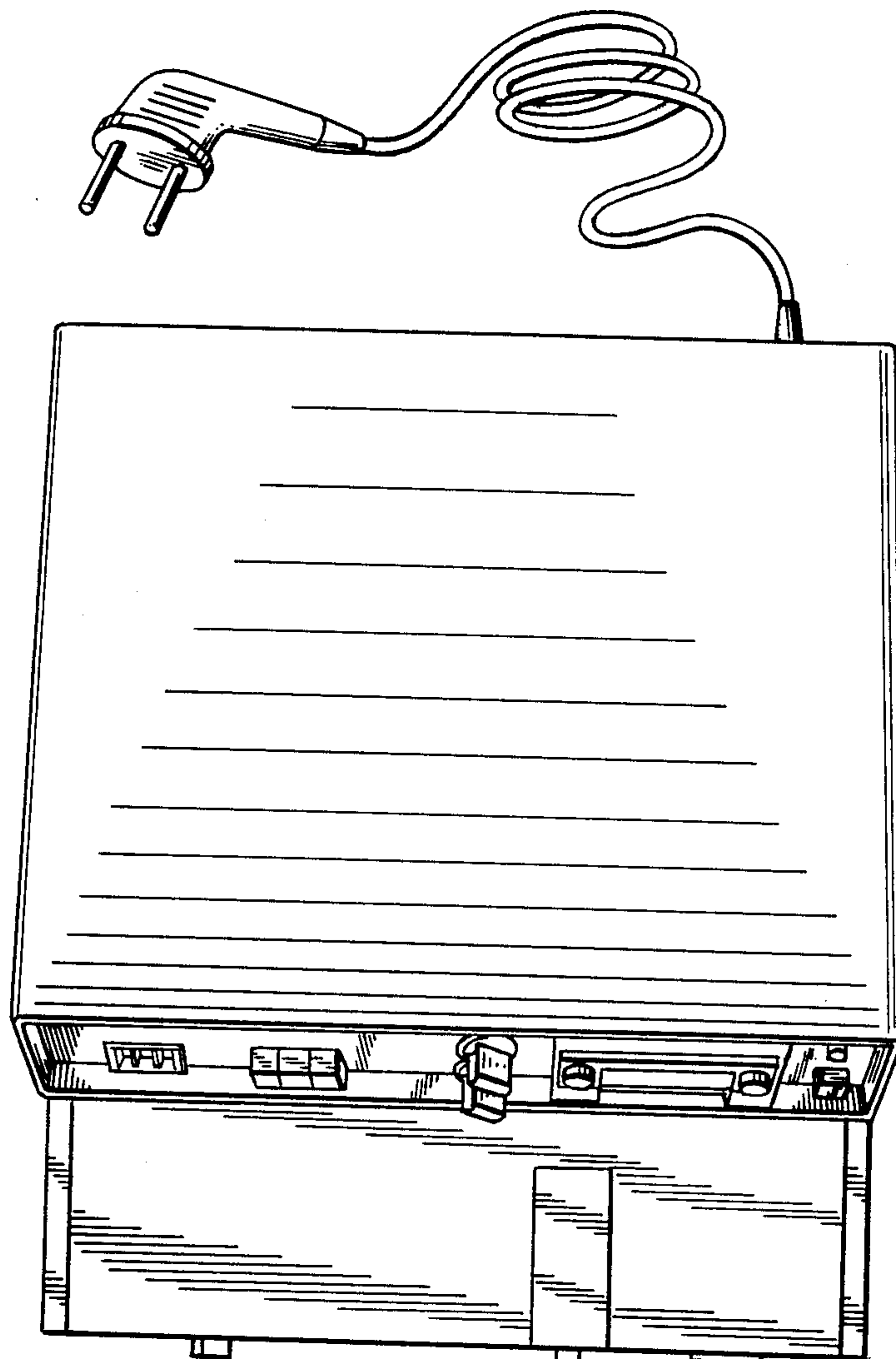


FIG.3

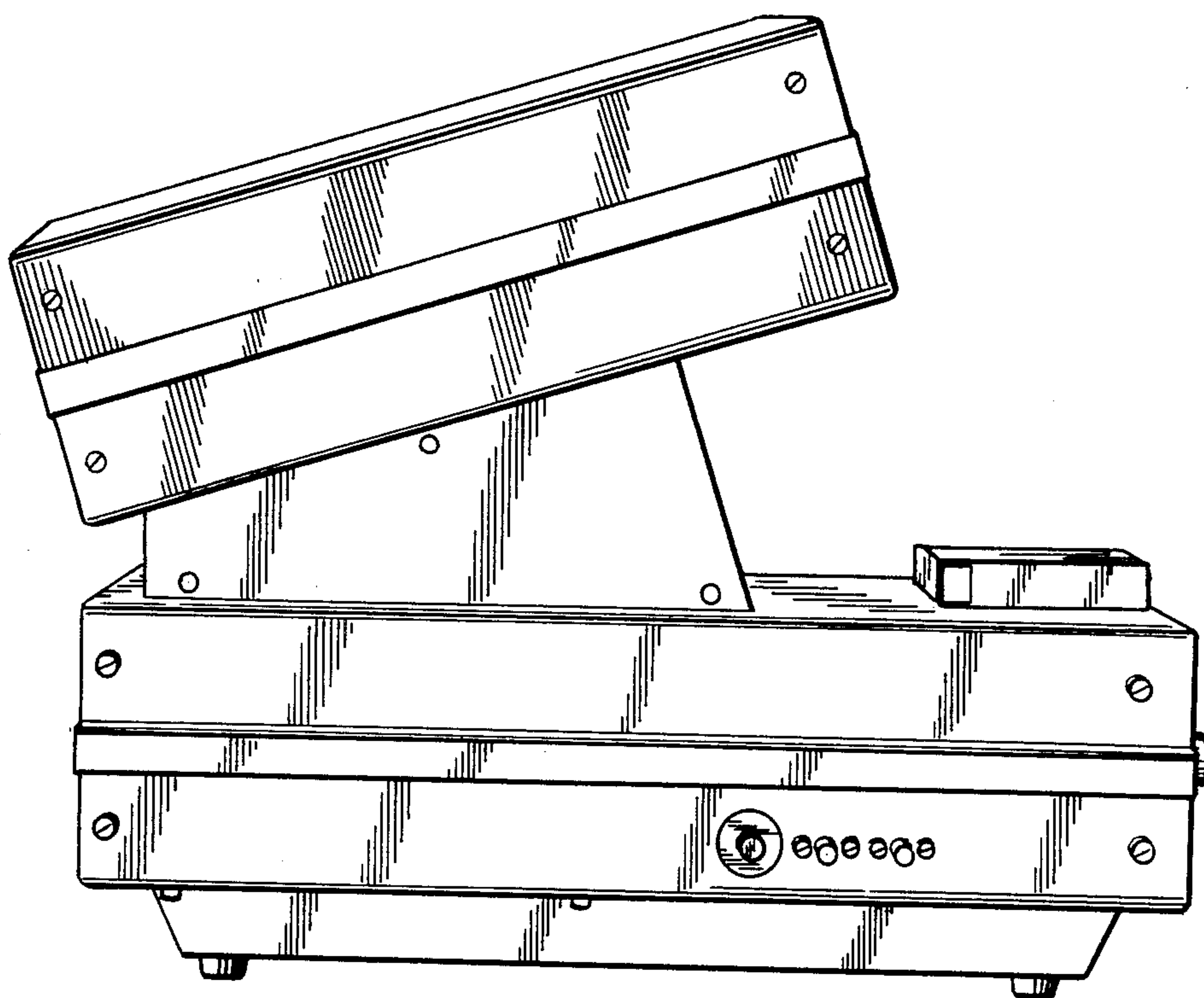


FIG.4

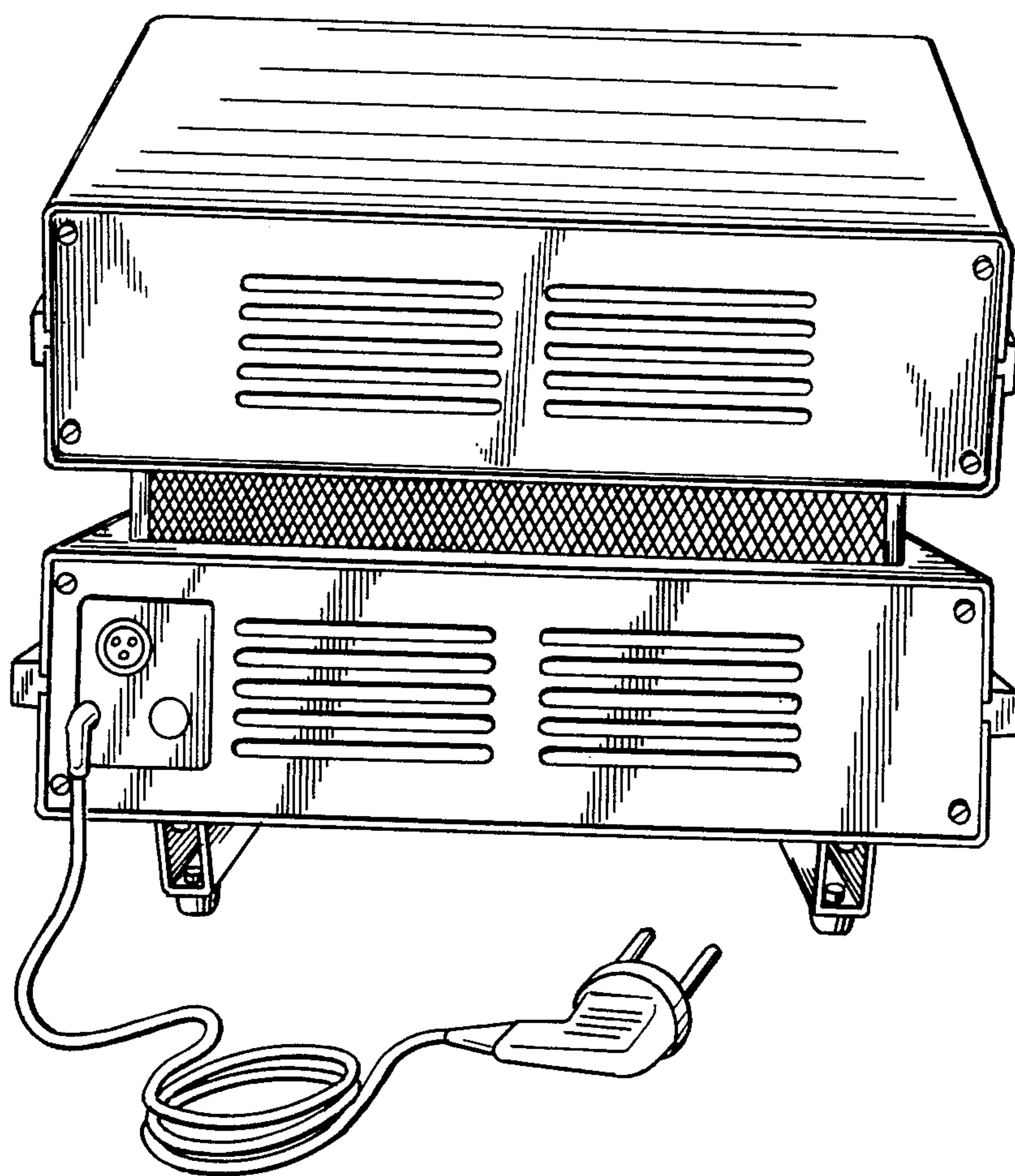


FIG.5